Application No.: 10/683,872 Amendment dated: March 27, 2007 Reply to Office Action of December 27, 2006 Attorney Docket No.: 0002,0004US1

This listing of claims will replace all prior versions and listings of claims in this application:

## b.) Listing of Claims

- 1. (Cancelled)
- 2. (Cancelled)
- 3. (Cancelled)
- 4. (Cancelled)
- 5. (Cancelled)
- 6. (Cancelled)
- 7. (Previously presented) An optical system as claimed in claim 9, wherein the ultraviolet radiation has a wavelength of 13 to 14 nanometers and the objective comprises a zone plate made from molybdenum (Mo), niobium (Nb), Technetium (Tc), or Ruthenium (Ru).
- 8. (Cancelled)
- $9. \ \ (Currently \ amended) \ \ An \ optical \ system \ comprising:$ 
  - an extreme ultraviolet radiation source:
  - a spectral filter that filters ultraviolet radiation generated by the source;
  - a reflective condenser that directs the ultraviolet radiation onto a target sample at an angle of between normal to the sample and 7 degrees off normal;
  - an aperture for spatially filtering the ultraviolet radiation;
  - an objective lens that forms an image of the ultraviolet radiation from the target sample; and
  - a spatially resolved detector for detecting the image of the sample formed by the objective lens.

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- 10. (Original) An optical system as claimed in claim 9, wherein the source is a laser-plasma source.
- 11. (Original) An optical system as claimed in claim 9, wherein the source is a gas discharge source.
- 12. (Previously presented) An optical system as claimed in claim 9, wherein the spectral filter is a multilayer notch filter.
- 13. (Original) An optical system as claimed in claim 9, wherein the condenser is a multilayer coated spherical surface.
- 14. (Currently amended) An optical system comprising:

an extreme ultraviolet radiation source;

a spectral filter that filters ultraviolet radiation generated by the source;

a reflective condenser that directs the ultraviolet radiation onto a sample at an angle of between normal to the sample and 7 degrees off normal;

an aperture for spatially filtering the ultraviolet radiation;

an objective lens that forms an image of the ultraviolet radiation from the sample; and

a spatially resolved detector for detecting the image of the sample formed by the objective lens; and

An optical system as claimed in claim 9, wherein a virtual source of the extreme ultraviolet radiation source formed by the condenser and a region of interest of the target sample, which is a mask, reside on a Rowland circle determined by the condenser

- 15. (Original) An optical system as claimed in claim 9, wherein the detector is a CCD camera
- (Original) An optical system as claimed in claim 9, wherein the detector is a CMOS camera.

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17. (Currently amended) An optical system comprising:

an extreme ultraviolet radiation source:

a spectral filter that filters ultraviolet radiation generated by the source;

a reflective condenser that directs the ultraviolet radiation onto a sample at an angle of between normal to the sample and 7 degrees off normal;

an aperture for spatially filtering the ultraviolet radiation;

an objective lens that forms an image of the ultraviolet radiation from the sample; and

a spatially resolved detector for detecting the image of the sample formed by the objective lens; and

An optical system as claimed in claim 9, wherein the objective lens comprises an achromatic Fresnel optic with a silicon refractive lens.

- 18. (Original) An optical system as claimed in claim 9, wherein the source uses emission from a copper target.
- 19. (Currently amended) An optical system comprising:

an extreme ultraviolet radiation source;

a spectral filter that filters ultraviolet radiation generated by the source:

a reflective condenser that directs the ultraviolet radiation onto a sample at an angle of between normal to the sample and 7 degrees off normal;

an aperture for spatially filtering the ultraviolet radiation;

an objective lens that forms an image of the ultraviolet radiation from the sample; and

a spatially resolved detector for detecting the image of the sample formed by the objective lens; and

An optical system as claimed in claim 9, wherein the objective lens comprises an achromatic Fresnel optic with a refractive lens made from copper.

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- 20. (Previously presented) An optical system as claimed in claim 9, wherein the objective lens comprises a zone plate lens.
- 21. (New) An optical system as claimed in claim 9, wherein the sample is a lithography mask.
- 22. (New) An optical system as claimed in claim 9, wherein the ultraviolet radiation has a wavelength of 13 to 14 nanometers and the objective comprises a zone plate made from molybdenum (Mo).
- 23. (New) An optical system as claimed in claim 9, wherein the ultraviolet radiation has a wavelength of 13 to 14 nanometers and the objective comprises a zone plate made from niobium (Nb).
- 24. (New) An optical system as claimed in claim 9, wherein the ultraviolet radiation has a wavelength of 13 to 14 nanometers and the objective comprises a zone plate made from technetium (Tc).
- 25. (New) An optical system as claimed in claim 9, wherein the ultraviolet radiation has a wavelength of 13 to 14 nanometers and the objective comprises a zone plate made from ruthenium (Ru).